## **Listing of Claims:**

- 1. (currently amended) An apparatus comprising:
  - a material source means for supplying a material to be deposited;
- an atomization means for producing a plurality of discrete particles from said material source means;
- a force application means <u>comprising a carrier gas</u> for propelling said plurality of discrete particles generally toward a substrate; and
- a collimation means <u>comprising a coflowing sheath gas which surrounds said carrier gas</u> for controlling the direction of flight of said plurality of discrete particles.
- 2. (previously presented) The apparatus of claim 1 additionally comprising means for sorting said plurality of discrete particles by size.
  - 3-9. (canceled)
- 10. (currently amended) The apparatus of claim [[9]] 1 wherein said coflowing sheath gas forms a boundary layer that prevents said plurality of discrete particles from depositing onto walls of an orifice nozzle.

11. (currently amended) A method of direct writing of a material, the method comprising the steps of:

supplying the material to be deposited;

atomizing the material to produce a plurality of discrete particles;

applying a force by employing a carrier gas to propel the plurality of discrete

particles generally toward a substrate;

collimating the plurality of discrete particles by surrounding the carrier gas with a coflowing sheath gas to control the direction of flight of the plurality of discrete particles; and depositing the plurality of discrete particles on the substrate.

- 12. (previously presented) The method of claim 11 additionally comprising the step of sorting the plurality of discrete particles by size.
- 13. (previously presented) The method of claim 12 wherein the sorting step comprises employing one or more virtual impactors.
  - 14-19. (canceled)
- 20. (currently amended) The method of claim 49 11 further comprising the step of the coflowing sheath gas forming a boundary layer, thereby preventing the plurality of discrete particles from depositing onto walls of an orifice nozzle.
- 21. (currently amended) The apparatus of claim 1 further comprising a virtual compactor impactor.

- 22. (currently amended) The apparatus of claim 21 wherein said virtual compactor impactor is placed after said atomization means.
- 23. (previously presented) The apparatus of claim 22 wherein said virtual impactor extracts excess carrier gas without substantially reducing the number of said discrete particles.
- 24. (previously presented) The apparatus of claim 22 wherein said virtual impactor sorts said plurality of discrete particles by size.
- 25. (previously presented) The apparatus of claim 22 further comprising two or more virtual impactors placed in series.
- 26. (previously presented) The apparatus of claim 1 further comprising a laser for processing said discrete particles.
- 27. (previously presented) The method of claim 11 further comprising the step of extracting excess carrier gas without substantially reducing the number of said discrete particles.
- 28. (currently amended) The method of claim 28 27 wherein the extracting step comprises employing a virtual impactor.
- 29. (previously presented) The method of claim 11 further comprising the step of placing two or more virtual impactors in series.

30. (previously presented) the discrete particles with a laser.

The method of claim 11 further comprising the step of processing